

Supplementary Material

Enhanced Electromagnetic Absorption Properties of the Double-Layer $Ti_3C_2T_x$ MXene Absorber with Orthogonal Microstructures

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Supplementary Material:

Fig. S1. Digital photo for $\text{Ti}_3\text{C}_2\text{T}_x$ MXene foam.

Fig. S2. EDS of the $\text{Ti}_3\text{C}_2\text{T}_x$ MXene foam.

Fig. S3. XRD pattern of Ti_3AlC_2 , $\text{Ti}_3\text{C}_2\text{T}_x$, and the $\text{Ti}_3\text{C}_2\text{T}_x$ MXene foam.

Fig. S4. 1/4 wavelength matching model for (a) the perpendicular and (b) the parallel sample.

Fig. S5. Cole-Cole images of (a) the perpendicular and (b) the parallel sample.

Fig. S6. $\varepsilon'' / f - \varepsilon'$ curves of (a) the perpendicular and (b) the parallel sample.

Fig. S7. $\varepsilon'' - f^{-1}$ curves of (a) the perpendicular and (b) the parallel sample.

Fig. S8 Electromagnetic wave reflection loss for the sample with the parallel end thickness of (a) 5%, (b) 10%, (c) 35%, (d) 40%, (e) 45%, (f) 50%, (g) 55%, (h) 60%, (i) 65%, (j) 70%, (k) 75%, (l) 80%, (m) 85%, (n) 90%, and (o) 95%, with electromagnetic wave incident from the parallel ends, separately.

Table S1 Electromagnetic wave reflection loss for samples with electromagnetic waves incident from the parallel ends.

Fig. S9 Electromagnetic wave reflection loss for the sample with the perpendicular end thickness of (a) 5%, (b) 10%, (c) 15%, (d) 20%, (e) 25%, (f) 30%, (g) 35%, (h) 40%, (i) 45%, (j) 50%, (k) 55%, (l) 60%, (m) 65%, (n) 70%, (o) 75%, (p) 80%, (q) 85%, (r) 90%, and (s) 95%, with electromagnetic wave incident from the perpendicular ends, separately.

Table S2 Electromagnetic wave reflection loss for samples with electromagnetic waves incident from the perpendicular ends.

Fig. S10 (a, c) Comparison of RL curves for single and double layer samples with the same thickness; (b, d) Comparison of RL curves for double-layer samples and their compositions, where parallel end thickness of 25% in (a, b) and 20% in (c, d).

Table S3 Electromagnetic wave absorption properties of some earlier $\text{Ti}_3\text{C}_2\text{T}_x$ MXene materials

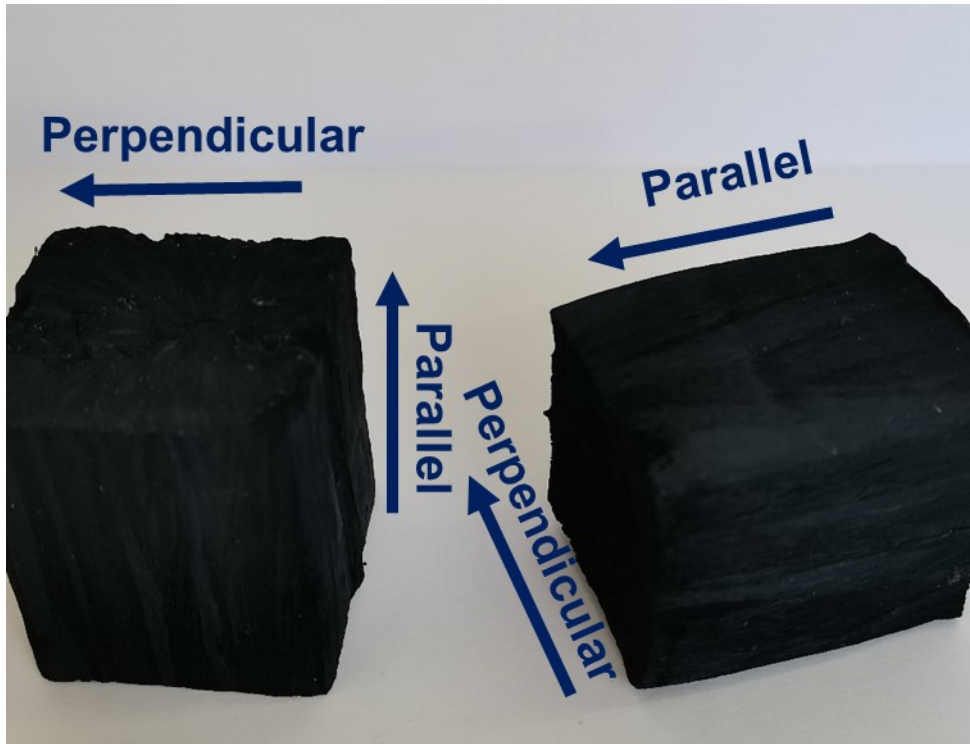


Fig. S1 Digital photo of the Ti₃C₂T_x MXene foam.

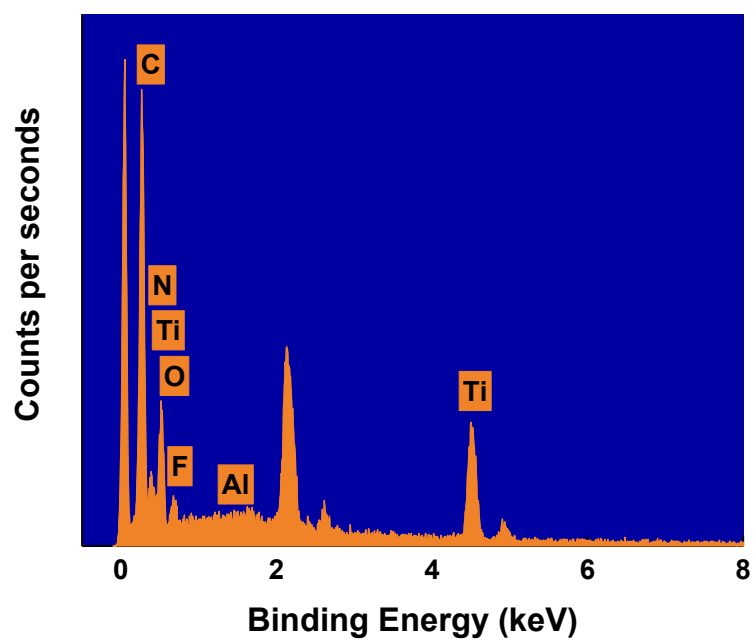


Fig. S2 EDS of the $\text{Ti}_3\text{C}_2\text{T}_x$ MXene foam.

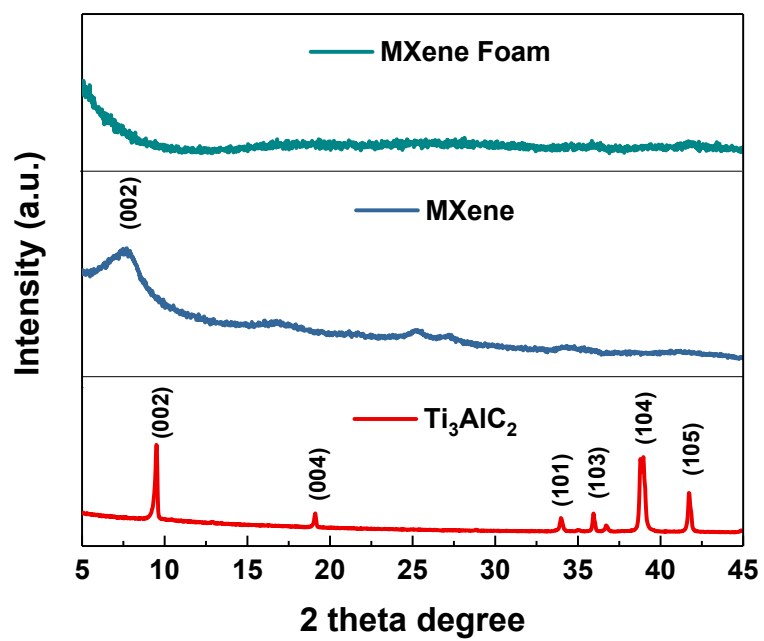


Fig. S3 XRD pattern of Ti_3AlC_2 , $\text{Ti}_3\text{C}_2\text{T}_x$, and the $\text{Ti}_3\text{C}_2\text{T}_x$ MXene foam.

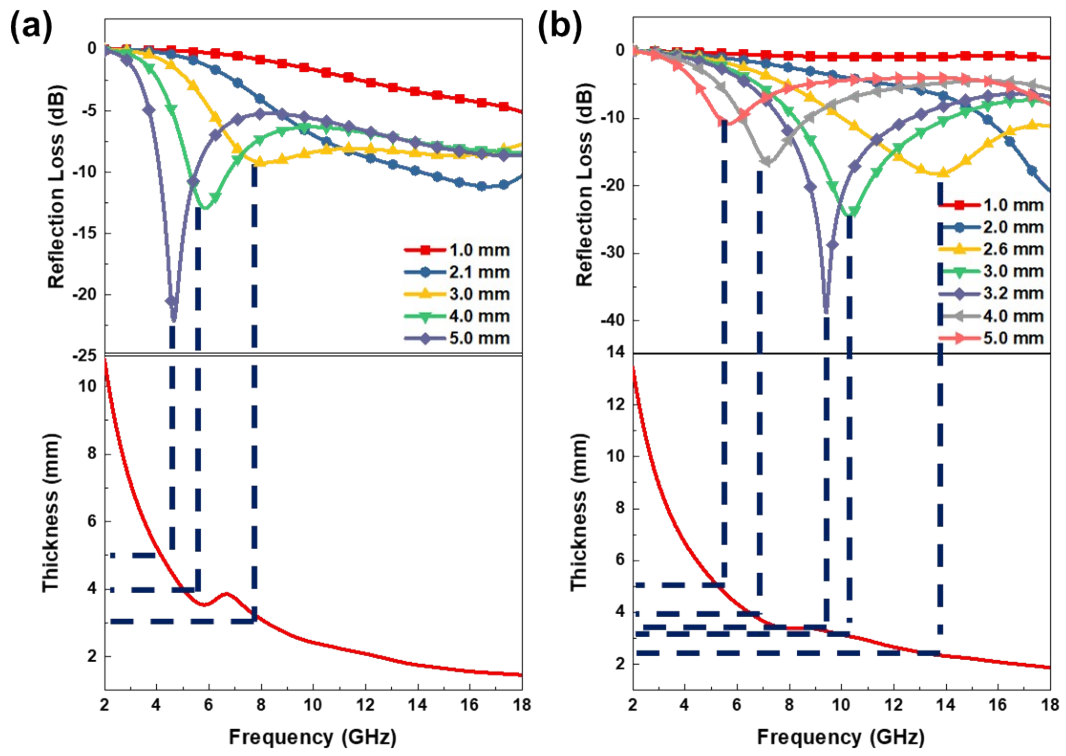


Fig. S4 1/4 wavelength matching model for (a) the perpendicular and (b) the parallel sample.

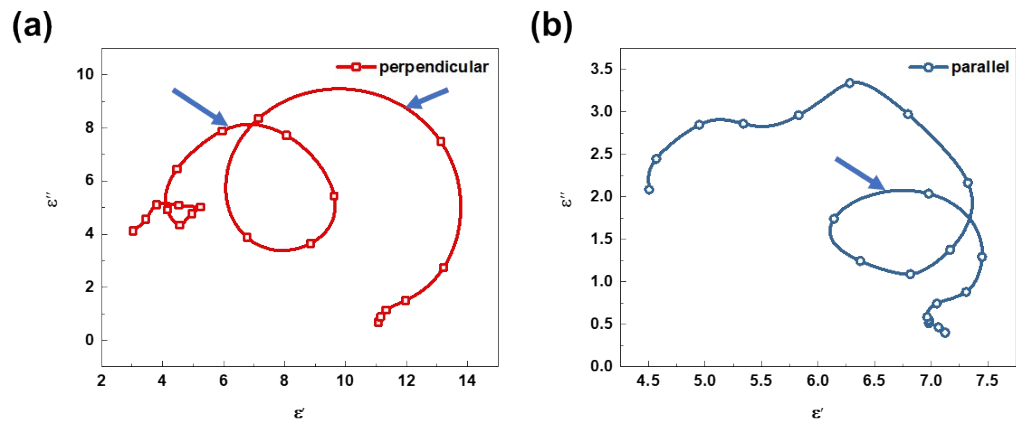


Fig. S5 Cole-Cole images of (a) the perpendicular and (b) the parallel sample.

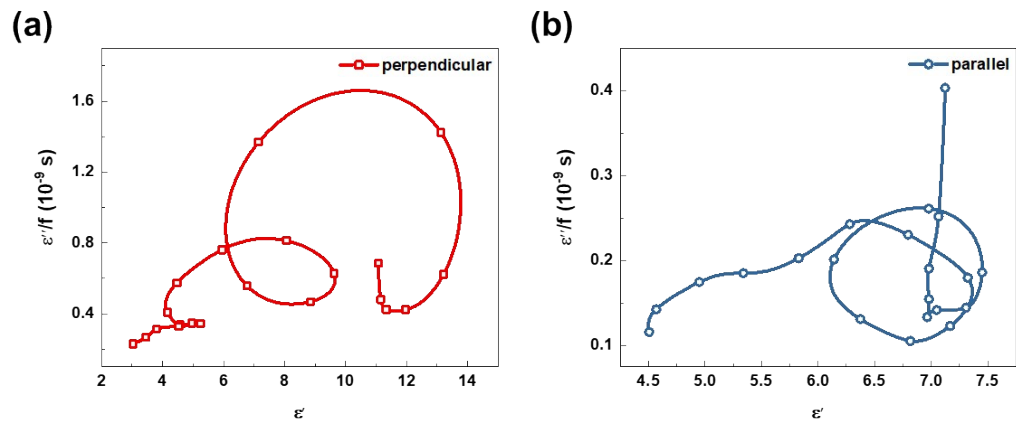


Fig. S6 $\varepsilon''/f - \varepsilon'$ curves of (a) the perpendicular and (b) the parallel sample.

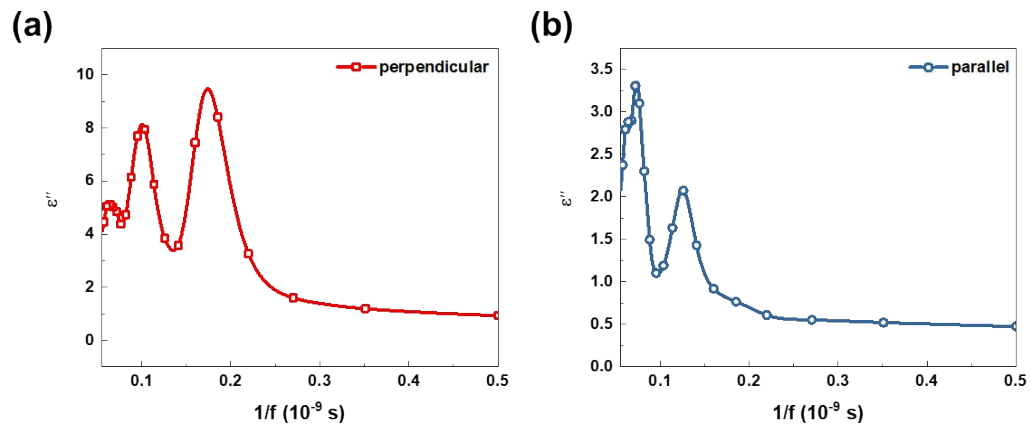


Fig. S7 $\epsilon'' - f^{-1}$ curves of (a) the perpendicular and (b) the parallel sample.

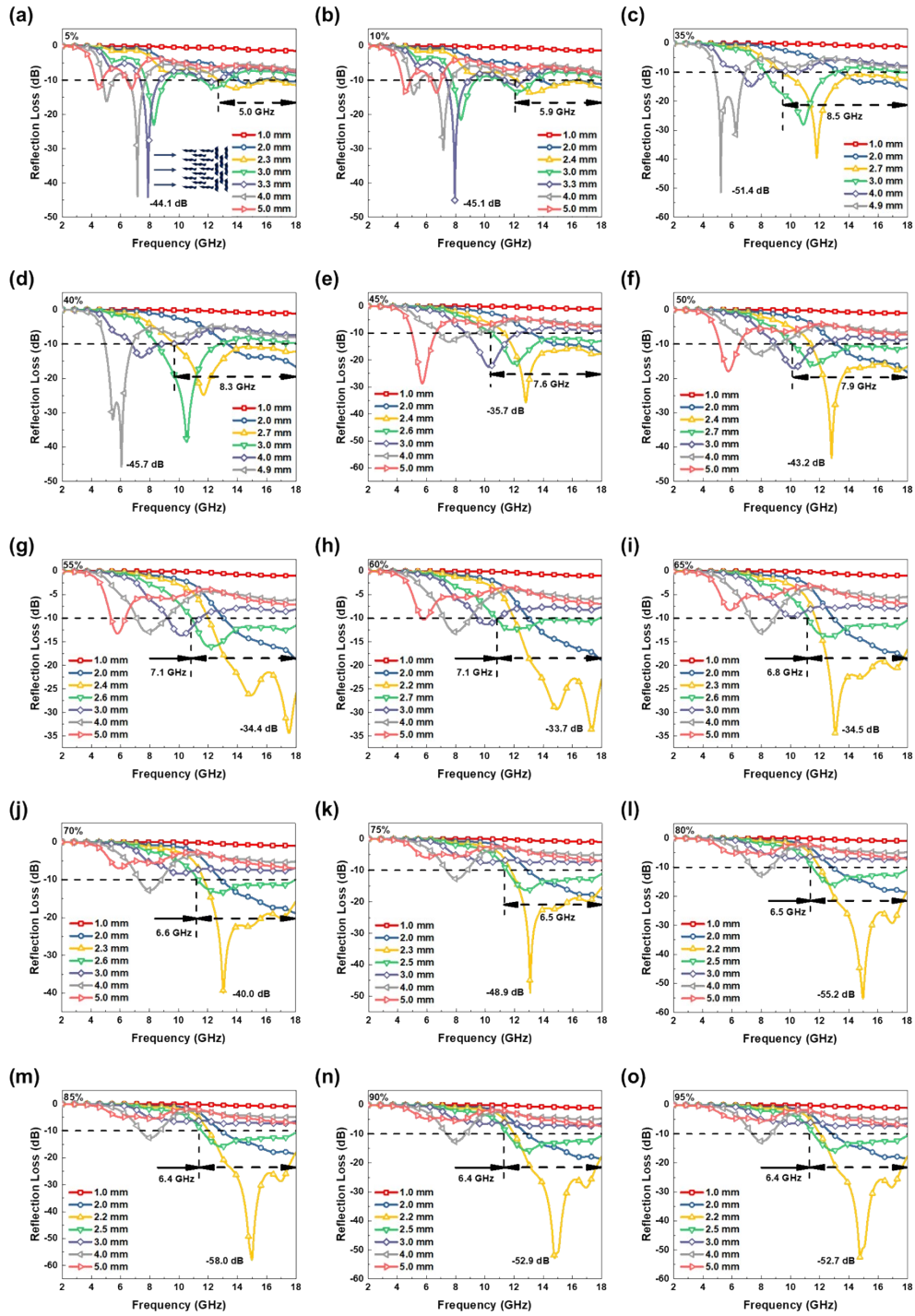


Fig. S8 Electromagnetic wave reflection loss for the sample with the parallel end thickness of (a) 5%, (b) 10%, (c) 35%, (d) 40%, (e) 45%, (f) 50%, (g) 55%, (h) 60%, (i) 65%, (j) 70%, (k) 75%, (l) 80%, (m) 85%, (n) 90%, and (o) 95%, with electromagnetic wave incident from the parallel ends, separately.

Table S1 Electromagnetic wave reflection loss for samples with electromagnetic waves incident from the parallel ends.

Matching layer thickness ratio	RL _{min} (dB)	Related Frequency of RL _{min} (GHz)	Related Thickness of RL _{min} (mm)	EAB _{max} (GHz)	Related Thickness of EAB _{max} (mm)
5%	-44.1	7.9	3.3	5.0	2.3
10%	-45.1	7.9	3.3	5.9	2.4
15%	-47.2	8.0	3.3	7.0	2.6
20%	-50.6	8.1	3.3	9.4	2.6
25%	-60.8	6.6	4.6	9.1	2.7
30%	-43.4	6.5	4.7	8.8	2.7
35%	-51.4	5.2	4.9	8.5	2.7
40%	-45.7	6.1	4.9	8.3	2.7
45%	-35.7	12.8	2.4	7.6	2.6
50%	-43.2	12.8	2.4	7.9	2.7
55%	-34.4	17.5	2.4	7.1	2.6
60%	-33.7	17.3	2.2	7.1	2.7
65%	-34.5	13.1	2.3	6.8	2.6
70%	-40.0	13.1	2.3	6.6	2.6
75%	-48.9	13.1	2.3	6.5	2.5
80%	-55.2	15.0	2.2	6.5	2.5
85%	-58.0	15.0	2.2	6.4	2.5
90%	-52.9	14.8	2.2	6.4	2.5
95%	-52.7	14.8	2.2	6.4	2.5

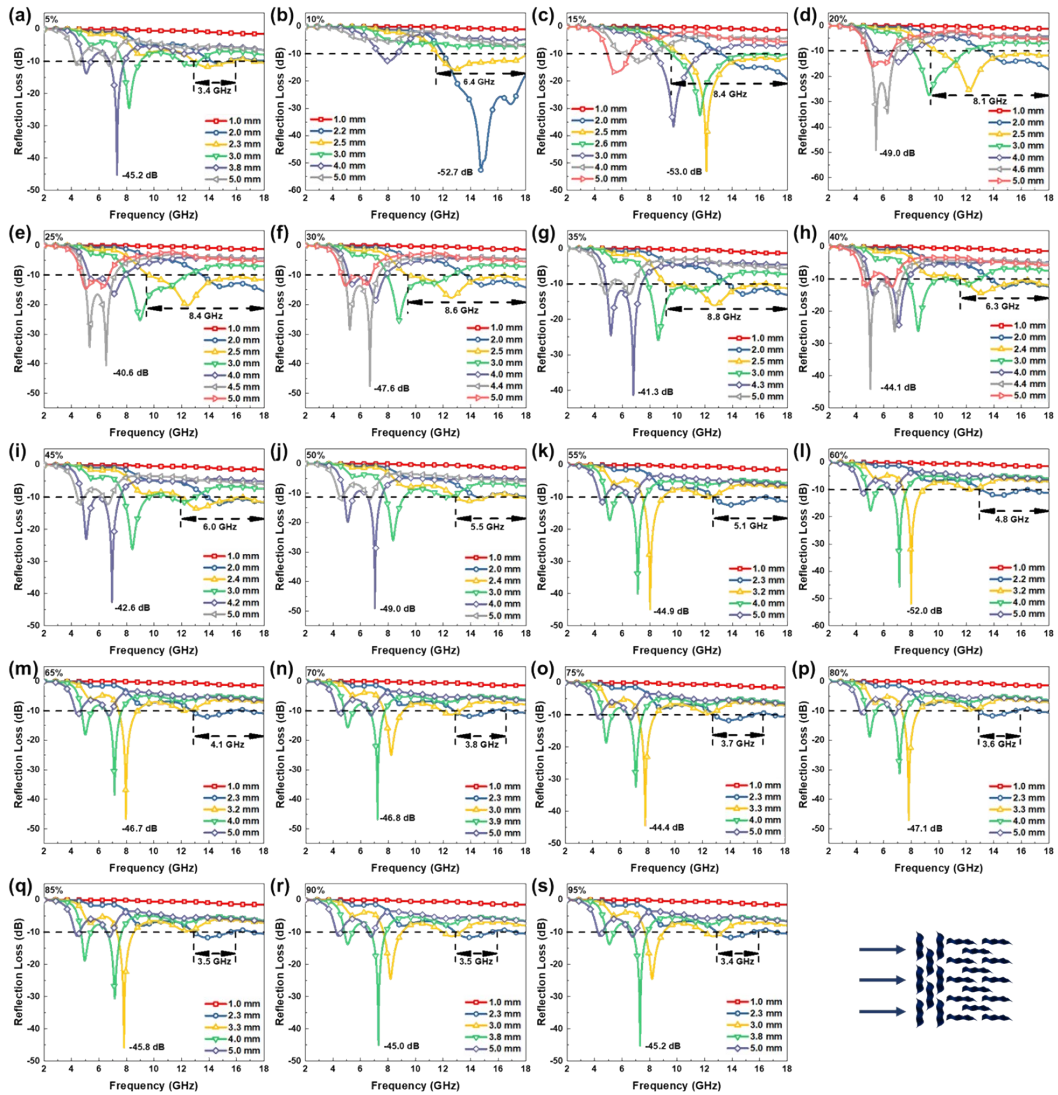


Fig. S9 Electromagnetic wave reflection loss for the sample with the perpendicular end thickness of (a) 5%, (b) 10%, (c) 15%, (d) 20%, (e) 25%, (f) 30%, (g) 35%, (h) 40%, (i) 45%, (j) 50%, (k) 55%, (l) 60%, (m) 65%, (n) 70%, (o) 75%, (p) 80%, (q) 85%, (r) 90%, and (s) 95%, with electromagnetic wave incident from the perpendicular ends, separately.

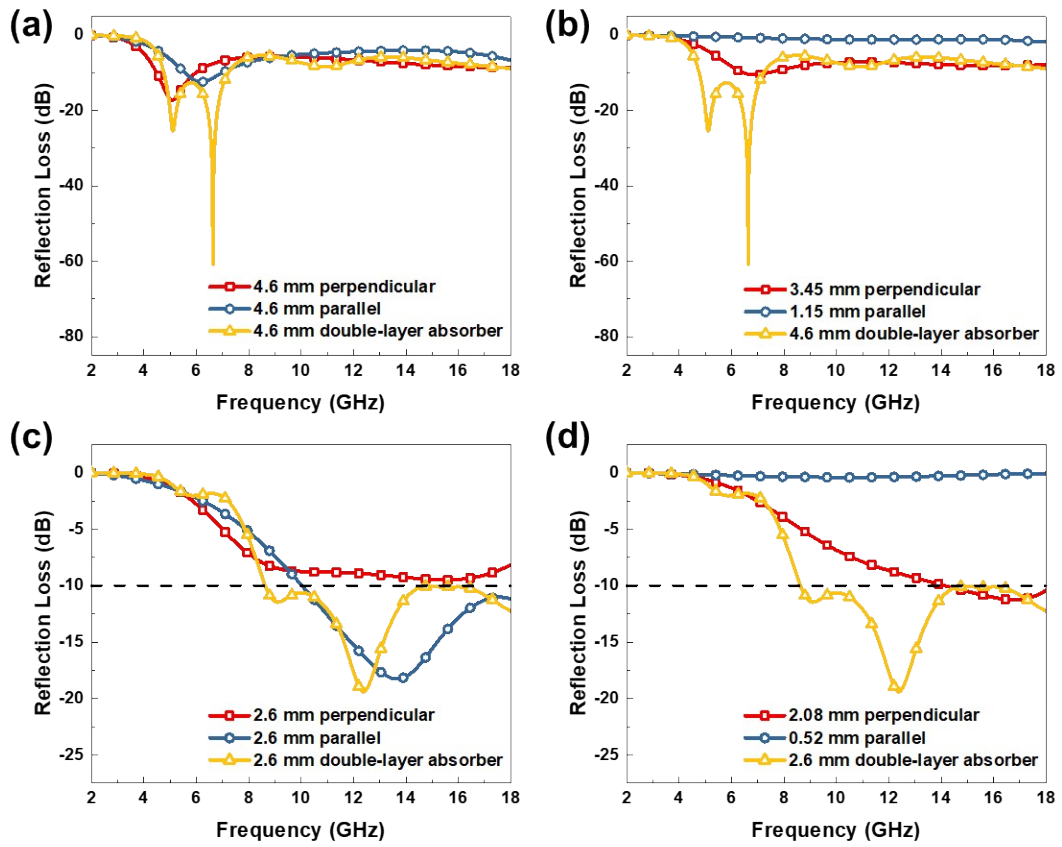


Fig. S10 (a, c) Comparison of RL curves for single and double layer samples with the same thickness; (b, d) Comparison of RL curves for double-layer samples and their compositions, where parallel end thickness of 25% in (a, b) and 20% in (c, d).

Table S2 Electromagnetic wave reflection loss for samples with electromagnetic waves incident from the perpendicular ends.

Matching layer thickness ratio	RL _{min} (dB)	Related Frequency of RL _{min} (GHz)	Related Thickness of RL _{min} (mm)	EAB _{max} (GHz)	Related Thickness of EAB _{max} (mm)
5%	-45.2	7.3	3.8	3.4	2.3
10%	-52.7	14.8	2.2	6.4	2.5
15%	-53.0	12.1	2.5	8.4	2.6
20%	-49.0	5.5	4.6	8.1	2.5
25%	-40.6	6.5	4.5	8.4	2.5
30%	-47.6	6.7	4.4	8.6	2.5
35%	-41.3	6.8	4.3	8.8	2.5
40%	-44.1	5.0	4.4	6.3	2.4
45%	-42.6	7.0	4.2	6.0	2.4
50%	-49.0	7.0	4.0	5.5	2.4
55%	-44.9	8.0	3.2	5.1	2.3
60%	-52.0	8.0	3.2	4.8	2.2
65%	-46.7	8.0	3.2	4.1	2.3
70%	-46.8	7.2	3.9	3.8	2.3
75%	-44.4	7.8	3.3	3.7	2.3
80%	-47.1	7.8	3.3	3.6	2.3
85%	-45.8	7.8	3.3	3.5	2.3
90%	-45.0	7.3	3.8	3.5	2.3
95%	-45.2	7.3	3.8	3.4	2.3

Table S3 Electromagnetic wave absorption properties of some earlier $\text{Ti}_3\text{C}_2\text{T}_x$ MXene materials

Samples	RL_{\min} (dB)	EAB_{\max} (GHz)	References
$\text{Ti}_3\text{C}_2\text{T}_x$ MXenes without delamination	~ -7	0	11
DMF delaminated $\text{Ti}_3\text{C}_2\text{T}_x$ MXenes	-41.9	~ 2.8	12
Ethyl alcohol delaminated $\text{Ti}_3\text{C}_2\text{T}_x$ MXene	-17.0	5.6	13
$\text{Ti}_3\text{C}_2\text{T}_x$ MXenes with Modified Surface	-48.4	2.8	14
Urchin-like ZnO- $\text{Ti}_3\text{C}_2\text{T}_x$ MXene	-26.3	1.4	15
3D PMMA@MXene@Ni ²⁺	-59.6	4.5	16
Sea urchin-like $\text{Ti}_3\text{C}_2\text{T}_x$ MXene@ZnO hollow spheres	-57.4	6.6	17
$\text{Ti}_3\text{C}_2\text{T}_x$ MXene@rGO aerogel	-31.2	5.4	18
$\text{Ti}_3\text{C}_2\text{T}_x$ MXene cellulose aerogel	-43.4	4.5	19
$\text{Ti}_3\text{C}_2\text{T}_x$ MXene/SiCnws lamellar foam	-55.7	4.5	20
$\text{Ti}_3\text{C}_2\text{T}_x$ MXene/PI aerogel	-41.8	6.5	21
Ni/ $\text{Ti}_3\text{C}_2\text{T}_x$ MXene/rGO aerogel	-75.2	7.3	22
$\text{Ti}_3\text{C}_2\text{T}_x$ MXene double-layer absorber with matching layer thickness of 20%	-50.6	9.4	This work
$\text{Ti}_3\text{C}_2\text{T}_x$ MXene double-layer absorber with matching layer thickness of 25%	-60.8	9.1	This work

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